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• Tanaka, Shigemi, c/o Technical Center  
Katsushika-ku, Tokyo (JP)• Inoue, Manabu, c/o Technical Center  
Katsushika-ku, Tokyo (JP)• Yamamoto, Tomitaka, c/o Technical Center  
Katsushika-ku, Tokyo (JP)

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(71) Applicant: DIPSOL CHEMICALS CO., LTD.

Tokyo (JP)

(72) Inventors:

• Oshima, Katsuhide, c/o Technical Center  
Katsushika-ku, Tokyo (JP)

(74) Representative: Setna, Rohan P. et al

Boult Wade Tennant

Verulam Gardens

70 Gray's Inn Road

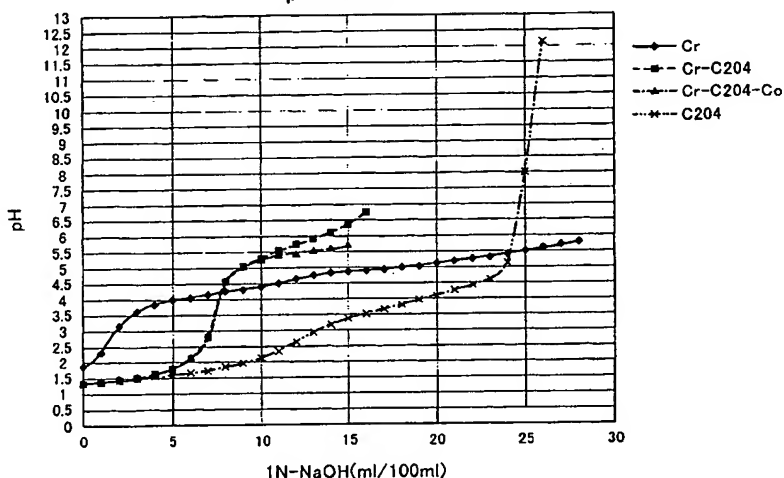
London WC1X 8BT (GB)

(54) **Processing solution for forming hexavalent chromium free and corrosion resistant conversion film on zinc or zinc alloy plating layers, hexavalent chromium free and corrosion resistant conversion film and method for forming the same**

(57) A processing solution for forming a hexavalent chromium free, corrosion resistant trivalent chromate conversion film on zinc or zinc alloy plating layers comprises a silicon compound; trivalent chromium and oxalic acid in a molar ratio ranging from 0.5 to 1.5, wherein the trivalent chromium is present in the form of a water-soluble complex with oxalic acid; and cobalt ions, which form a hardly soluble metal salt with oxalic acid and are

stably present in the processing solution without causing any precipitation, wherein the solution reacts with zinc when bringing it into contact with the zinc or zinc alloy plating to form a hexavalent chromium free, corrosion resistant, trivalent chromate conversion film containing zinc, chromium, cobalt, oxalic acid and silicon on the plating. This solution can provide a corrosion resistant trivalent chromate conversion film excellent in the corrosion resistance after heating.

FIG. 1  
pH curves



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## Description

**[0001]** Processing Solution for Forming Hexavalent Chromium Free and Corrosion Resistant Conversion Film on Zinc or Zinc Alloy Plating Layers, Hexavalent Chromium Free and Corrosion Resistant Conversion Film and Method for Forming the Same

## Background of The Invention

**[0002]** The present invention relates to a processing solution for forming a hexavalent chromium free and corrosion resistant conversion film on zinc or zinc alloy plating layers, a hexavalent chromium free and corrosion resistant conversion film and a method for forming the hexavalent chromium free and corrosion resistant conversion film.

**[0003]** As methods for rust preventing the surface of a metal, there has been known a zinc or zinc alloy-plating method. However, it is not possible to ensure sufficient corrosion resistance of the metal by such plating alone. For this reason, there has widely been adopted, in this industrial field, the treatment with chromic acid containing hexavalent chromium or the so-called chromate treatment after the plating. Nevertheless, it has recently been pointed out that the hexavalent chromium may adversely affect the human body and the environment and there has correspondingly been such a strong and active trend that the use of hexavalent chromium should be controlled.

**[0004]** As one of the substituent techniques therefor, the formation of a corrosion resistant conversion film, in which trivalent chromium is used, has been known. For instance, Japanese Examined Patent Publication (hereunder referred to as "J.P. KOKOKU") No. Sho 63-015991 discloses a method, which comprises the step of treating the surface of a metal with a bath containing a mixture of trivalent chromium and a fluoride, an organic acid, an inorganic acid and/or a metal salt such as cobalt sulfate. However, a fluoride is used in this plating bath and therefore, a problem of environmental pollution would arise. In addition, J.P. KOKOKU No. Hei 03-010714 discloses a method, which makes use of a plating bath comprising a mixture of trivalent chromium and an oxidizing agent, an organic acid, an inorganic acid and/or a metal salt such as a cerium salt. However, this method makes use of an oxidizing agent and cerium and therefore, the trivalent chromium may possibly be oxidized into hexavalent chromium, during the processing and/or the storage of the bath.

**[0005]** Furthermore, Japanese Un-Examined Patent Publication (hereunder referred to as "J.P. KOKAI") No. 2000-509434 discloses a method, which comprises the step of treating the surface of a metal using a plating bath comprising 5 to 100 g/L of trivalent chromium and nitrate residues, an organic acid and/or a metal salt such as a cobalt salt. This method uses, for instance, trivalent chromium in a high concentration and the plating operation is carried out at a high temperature. Therefore, this method is advantageous in that it can form a thick film and ensure good corrosion resistance. However, the method suffers from a problem in that it is difficult to stably form a dense film and that the method cannot ensure the stable corrosion resistance of the resulting film. Moreover, the processing bath contains trivalent chromium in a high concentration and also contains a large amount of an organic acid. This makes the post-treatment of the waste water difficult and results in the formation of a vast quantity of sludge after the processing. Although one can recognize that it is advantageous to use a processing solution free of any hexavalent chromium for ensuring the environmental protection, the method suffers from a serious problem in that it may give a new burden to the environment such that the method generates a vast quantity of waste.

**[0006]** Moreover, there have been proposed a method for processing the surface of a metal with a bath containing trivalent chromium in a low concentration and an organic acid and a metal salt such as a nickel salt (U.S. Patent No. 4,578,122) and a processing method, which makes use of a bath containing trivalent chromium in a low concentration and an organic acid (U.S. Patent No. 5,368,655). However, these methods never ensure sufficient corrosion resistance of the resulting film as compared with the conventional hexavalent chromate treatment.

**[0007]** As has been discussed above in detail, it has been known that if zinc or a zinc alloy are immersed in a solution of a trivalent chromium salt, a chromium-containing film is formed thereon.

**[0008]** However, the resulting film is insufficient in the corrosion resistance effect. Therefore, it is necessary to increase the thickness of the resulting film by increasing the chromium concentration in the processing solution, raising the processing temperature and extending the processing time in order to obtain a film having the corrosion resistance effect identical to that achieved by the conventional corrosion resistant conversion film derived from hexavalent chromium. However, this leads to an increase in the energy consumption and in the quantity of the waste sludge, which is not desirable from the viewpoint of the environmental protection.

## Summary of The Invention

**[0009]** Accordingly, it is an object of the present invention to provide a thin, hexavalent chromium free film, which is applied onto the surface of zinc or zinc alloy plating layers, which have corrosion resistance identical to or higher than that achieved by the conventional hexavalent chromium-containing conversion film and which can be formed using a

processing solution having a low concentration. More specifically, it is an object of the present invention to provide a hexavalent chromium free, corrosion resistance, trivalent chromate-conversion film excellent, in particular, in corrosion resistance after heating.

[0010] Another object of the present invention is to provide a processing solution used for forming such a hexavalent chromium free, corrosion resistance, trivalent chromate-conversion film and a method for forming the film.

[0011] Moreover, it is also an object of the present invention to provide a method for forming such a film in which the same devices and processes used in the formation of the conventional hexavalent chromate film can be used as such without any modification.

[0012] The present invention has been developed on the basis of such a finding that the foregoing problems associated with the conventional techniques can effectively be solved by forming a trivalent chromate conversion film containing a hardly soluble cobalt oxalate salt and Si, while using a trivalent chromate-conversion processing solution (plating bath) having a specific composition, after depositing a zinc plating layer on a substrate.

[0013] According to an aspect of the present invention, there is provided a processing solution for forming a hexavalent chromium free, corrosion resistance trivalent chromate film on zinc or zinc alloy plating layers and the processing solution comprises:

a silicon compound;

trivalent chromium and oxalic acid in a mole ratio ranging from 0.5/1 to 1.5/1, wherein the trivalent chromium is present in the form of a water-soluble complex with oxalic acid; and

cobalt ions, which are stably present in the processing solution without causing any precipitation by forming a hardly soluble metal salt with oxalic acid;

wherein the solution reacts with zinc when bringing it into contact with the zinc or zinc alloy plating to form a hexavalent chromium free, corrosion resistance, trivalent chromate film containing zinc, chromium, cobalt, oxalic acid and  $\text{SiO}_2$  on the plating.

[0014] According to another aspect of the present invention, there is provided the foregoing hexavalent chromium free, corrosion resistance, trivalent chromate conversion film containing zinc, chromium, cobalt, oxalic acid and  $\text{SiO}_2$  and formed on zinc or zinc alloy plating layers, wherein the  $\text{SiO}_2$  content thereof ranges from 1 to 10 mg/dm<sup>2</sup>, the mass ratio of chromium to (chromium + zinc)  $[\text{Cr}/(\text{Cr}+\text{Zn})]$  is not less than 15/100, the mass ratio of cobalt to (chromium + cobalt)  $[\text{Co}/(\text{Cr} + \text{Co})]$  ranges from 1/100 to 40/100 and the mass ratio of the oxalic acid to (chromium + oxalic acid)  $[\text{oxalic acid}/(\text{Cr} + \text{oxalic acid})]$  ranges from 5/100 to 50/100.

[0015] According to a further aspect of the present invention, there is provided a method for forming a hexavalent chromium free, corrosion resistance, trivalent chromate conversion film, which comprises the step of bringing zinc or zinc alloy plating into contact with the foregoing processing solution.

## Brief Description of the Drawings

[0016]

Fig. 1 is a graph showing pH curves of Cr, an oxalic acid-Cr system, an oxalic acid-Cr-Co system and oxalic acid. Fig. 2 is a chart showing the AES (Auger Electron Spectroscopy) analysis of the film according to the present invention.

Fig. 3 is a chart showing the HPLC (High Performance Liquid Chromatography) analysis of the film according to the present invention.

## Description of the Preferred Embodiments

[0017] The substrates used in the present invention may be a variety of metals such as iron, nickel and copper, alloys thereof and metals or alloys such as aluminum, which have been subjected to zincate treatment and the substrate may have a variety of shapes such as plate-like, rectangular prism-like, column-like, cylindrical and spherical shapes.

[0018] The foregoing substrate is plated with zinc or a zinc alloy according to the usual method. The zinc-plating layer may be deposited on the substrate using either of baths, for instance, acidic baths such as a sulfuric acid bath, an ammonium chloride bath and a potassium chloride bath, and alkaline baths such as an alkaline non-cyanide bath and an alkaline cyanide bath.

[0019] In addition, examples of zinc alloy plating are zinc-iron alloy plating, zinc-nickel alloy plating having a rate of nickel-co-deposition ranging from 5 to 20% by mass, zinc-cobalt alloy plating and tin-zinc alloy plating. The thickness of the zinc or zinc alloy plating to be deposited on the substrate may arbitrarily be selected, but it is desirably not less than 1  $\mu\text{m}$  and preferably 5 to 25  $\mu\text{m}$ .

in the processing solution, cobalt ions react with oxalic acid present in the processing solution in its free state to thus form precipitates of cobalt oxalate. As a result, the processing solution cannot form any chemical conversion film (coating) having excellent corrosion resistance.

**[0033]** Moreover, if an Si compound is added to the processing solution, the cobalt oxalate-containing trivalent chromate film formed by the method, as will be detailed later, using the processing solution of the present invention has a two layered structure, which consists of an upper layer mainly comprising Si and O and a lower layer mainly comprising Cr and O and the addition of such an Si compound would permit the reduction of the thickness of the Cr-containing lower layer without the sacrifice of the corrosion resistance.

**[0034]** If zinc or zinc alloy plating is brought into contact with the processing solution according to the present invention, the components of the solution react with zinc to thus form a hexavalent chromium free, corrosion resistance, trivalent chromate film comprising zinc, chromium, cobalt and oxalic acid on the zinc or zinc alloy plating.

**[0035]** The hexavalent chromium free, corrosion resistance, trivalent chromate film according to the present invention, which is formed by bringing zinc or zinc alloy plating into contact with the foregoing processing solution is a hexavalent chromium free, corrosion resistance, trivalent chromate film formed on the zinc or zinc alloy plating and comprising zinc, chromium, cobalt, oxalic acid and  $\text{SiO}_2$ .

**[0036]** The content of  $\text{SiO}_2$  in the resulting trivalent chromate film ranges from 1 to 10  $\text{mg/dm}^2$  and preferably 1 to 5  $\text{mg/dm}^2$ .

**[0037]** The mass ratio of chromium relative to (chromium + zinc)  $[\text{Cr}/(\text{Cr} + \text{Zn})]$  is not less than 15/100 and preferably 20/100 to 60/100.

**[0038]** The mass ratio of cobalt relative to (chromium + cobalt)  $[\text{Co}/(\text{Cr} + \text{Co})]$  ranges from 1/100 to 40/100 and preferably 4/100 to 40/100.

**[0039]** The mass ratio of oxalic acid relative to (chromium + oxalic acid)  $[\text{oxalic acid}/(\text{Cr} + \text{oxalic acid})]$  ranges from 5/100 to 50/100 and preferably 15/100 to 50/100.

**[0040]** The resulting film has the high corrosion resistance after heating when the thickness of the resulting film is not less than 0.05  $\mu\text{m}$  and preferably 0.05 to 2  $\mu\text{m}$ .

**[0041]** As the method for bringing the zinc or zinc alloy plating into contact with the foregoing processing solution according to the present invention, it is usual to immerse an article plated with zinc or zinc alloy in the foregoing processing solution. For instance, such an article is immersed in the solution maintained at a temperature ranging from 10 to 40°C and more preferably 20 to 30°C for preferably 5 to 600 seconds and more preferably 15 to 120 seconds.

**[0042]** In this connection, the subject to be treated may be immersed in a dilute nitric acid solution in order to activate the surface thereof, before it is subjected to the chromate treatment.

**[0043]** The conditions and processing operations other than those described above may be determined or selected in accordance with the conventional hexavalent chromate processing.

**[0044]** Moreover, a topcoat film may be applied onto the hexavalent chromium free, corrosion resistance, trivalent chromate film and this would permit the further improvement of the corrosion resistance of the film. In other words, this is a quite effective means for imparting more excellent corrosion resistance to the film. For instance, the zinc or zinc alloy plating is first subjected to the foregoing trivalent chromate treatment, followed by washing the plating with water, subjecting the plating to immersion or electrolyzation in a topcoating solution and then drying the processed article. Alternatively, the article is subjected to immersion or electrolyzation in a topcoating solution after the trivalent chromate treatment and the subsequent drying treatment, and then dried. The term "topcoat" effectively used herein means not only an inorganic film of, for instance, a silicate or a phosphoric acid salt, but also an organic film of, for instance, polyethylene, polyvinyl chloride, polystyrene, polypropylene, methacrylic resin, polycarbonate, polyamide, polyacetal, fluorine plastic, urea resin, phenolic resin, unsaturated polyester resin, polyurethane, alkyd resin, epoxy resin or melamine resin.

**[0045]** The topcoating liquids for forming such a topcoat film usable herein may be, for instance, DIPCOAT W, CC445 available from Dipsol Chemicals Co., Ltd.. The thickness of the topcoat film may arbitrarily be selected, but it desirably ranges from 0.1 to 30  $\mu\text{m}$ .

**[0046]** Moreover, a dye may be incorporated into the topcoating liquid or the trivalent chromate conversion film may once be treated with the topcoating liquid and then the trivalent chromate conversion film may be treated with a liquid containing a dye, in order to pigment the topcoat film. Reaction Mechanism of Film-Formation

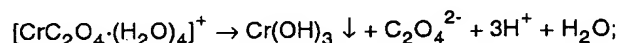
**[0047]** The reaction mechanism of the trivalent chromate conversion film-formation according to the present invention can be supposed to be as follows:

(i) The occurrence of a Zn dissolution reaction by the action of hydrogen ions and an oxidizing agent such as nitric acid;

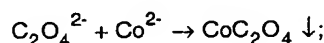
(ii) The consumption of hydrogen ions and an increase of the pH value at the interface to be plated subsequent to the dissolution reaction:



(iii) The reduction of the stability of the Cr (trivalent)-oxalic acid chelate, the formation and deposition of Cr hydroxide, and the generation of excess oxalic acid (in case of 1/m=1), due to the increase in the pH value:



(iv) The formation and deposition of a hardly soluble metal salt through the reaction of the excess oxalic acid with cobalt ions:



(v) The simultaneous deposition and growth of  $\text{SiO}_2$  due to the increase in the pH value and the termination of the reaction.

[0048] The pH curves shown in Fig. 1 would support these reaction mechanisms. As will be seen from the pH curves observed for oxalic acid and the oxalic acid-Cr system, the stable complex of oxalic acid with Cr loses its stability at a pH value of not less than about 4.5. In addition, the pH curve observed for the oxalic acid-Cr-Co system likewise indicates that precipitates of Co are also formed at a pH level of not less than about 4.5.

[0049] Moreover, it would be predicted from the following experimental results that insoluble cobalt oxalate is formed during the film-formation.

Experiment 1: Any precipitate is not formed even when a Co salt is added to a stable oxalic acid-Cr complex solution.  
Experiment 2: Any precipitate is not formed even when oxalic acid is further added to a stable oxalic acid-Cr complex solution.

Experiment 3: If an additional oxalic acid is added to the liquid of Experiment 1 (Co ions are present therein), precipitates are formed.

Experiment 4: If a Co salt is added to the liquid of Experiment 2 (excess oxalic acid ions are present therein), precipitates are formed.

Experiment 5: (In case where any chelate is not formed), if a Co salt is added to an oxalic acid solution, precipitates are formed.

Results obtained in the Analysis of Films:

[0050] As has been discussed above, in the trivalent chromate film of the present invention, cobalt oxalate having quite low solubility in water is formed at the interface of the plated film during the reaction for forming the chemical conversion film and therefore, the oxalate is incorporated into the trivalent chromium-containing chemical conversion film during the formation thereof to make the resulting film dense and to thus give a firm corrosion resistant film.

[0051] In fact, when using a solution having a ratio: chromium: oxalic acid = 1: 1 (molar ratio) and containing cobalt ions and colloidal silica, the results listed in the following Table 1 are obtained by analyzing the resulting trivalent chromate film. Certainly, the result as calculated from the molar ratio is approximately in consistent with cobalt oxalate ( $\text{C}_2\text{O}_4$ ). Moreover, the data shown in the AES analysis chart indicates that the lower layer is abundant with Cr, while the upper layer is rich in  $\text{SiO}_2$ .

Table 1

| Cr (mg/dm <sup>2</sup> ) | Co (mg/dm <sup>2</sup> ) | $\text{C}_2\text{O}_4^{2-}$ (mg/ dm <sup>2</sup> ) | $\text{SiO}_2$ (mg/dm <sup>2</sup> ) | Thickness of Film (nm)          |                                 |
|--------------------------|--------------------------|--|--------------------------------------|---------------------------------|---------------------------------|
| 0.3                      | 0.04                     | 0.06   | 1.2                                  | Si O Layer: 48<br>(upper layer) | Cr-O Layer: 34<br>(lower layer) |

[0052] In this connection, the thickness of the film was determined by the AES (Auger Electron Spectroscopy: Fig. 2) technique. In addition, the analysis of Cr, Co, Si and oxalic acid were carried out by dissolving the film in methanesulfonic acid and inspecting the solution for Cr, Co and Si using a device: AA (Atomic Absorption spectrometer) and for oxalic acid according to the HPLC (High Performance Liquid Chromatography: Fig. 3) technique.

[0053] As has been described above in detail, the present invention permits the formation of a trivalent chromate

film directly on zinc or zinc alloy plating layers. The plated article obtained according to this method has not only the corrosion resistance due to the zinc or zinc alloy plating as such, but also the excellent corrosion resistance due to the presence of the trivalent chromate film. Moreover, the processing solution used in the present invention comprises trivalent chromium in a low concentration and therefore, the present invention is quite advantageous from the viewpoint of the waste water treatment and production and processing cost. The film obtained by directly forming trivalent chromate on the plating possesses not only corrosion resistance, resistance to salt water and after heating resistance identical to those observed for the conventional hexavalent chromium-containing film, but also excellent resistance to after heating-corrosion, and therefore, the film of the present invention can widely be used in a variety of fields in the future.

[0054] The present invention will hereunder be described in more detail with reference to the following Examples and Comparative Examples, but the present invention is not restricted to these specific Examples at all. Examples 1 to 5

[0055] A steel plate, which had been plated using a Zincate Zn plating bath (available from Dipsol Chemicals Co., Ltd.; NZ-98) in a thickness of 8 $\mu$ m, was immersed in a trivalent chromate-containing processing solution having a composition as shown in the following Table 2 and then washed with water and dry.

Table 2

| Ex. No.                            | 1   | 2   | 3   | 4   | 5   |
|------------------------------------|-----|-----|-----|-----|-----|
| Cr <sup>3+</sup> (g/L)             | 1   | 3   | 4   | 5   | 5   |
| NO <sub>3</sub> <sup>-</sup> (g/L) | 5   | 12  | 20  | 25  | 30  |
| PO <sub>4</sub> <sup>-</sup> (g/L) | 0   | 0   | 0   | 0.3 | 1   |
| Oxalic acid (g/L)                  | 3   | 8   | 12  | 15  | 15  |
| Malonic acid (g/L)                 | 0   | 0.2 | 0   | 0   | 0   |
| Succinic acid (g/L)                | 0   | 0   | 0   | 0   | 2   |
| Co <sup>2+</sup> (g/L)             | 0.2 | 0.5 | 1   | 1   | 1   |
| Si (g/L)                           | 2   | 2   | 5   | 2   | 5   |
| pH of Processing Soln.             | 2.0 | 2.0 | 2.3 | 1.8 | 2.2 |
| Processing Temp. (°C)              | 30  | 30  | 30  | 30  | 30  |
| Processing time (sec.)             | 60  | 40  | 40  | 40  | 40  |

[0056] In Table 2, the Cr<sup>3+</sup> sources used were CrCl<sub>3</sub> (in Examples 3 and 5) and Cr(NO<sub>3</sub>)<sub>3</sub> (in Examples 1, 2 and 4); the oxalic acid used was dihydrate; and the Co<sup>2+</sup> source used was Co(NO<sub>3</sub>)<sub>2</sub>. Further the NO<sub>3</sub><sup>-</sup> sources used were HNO<sub>3</sub> (in Examples 3 and 5) and NaNO<sub>3</sub> (in Examples 1, 2 and 4). As the Si source, acidic colloidal silica (SNOWTEX O available from Nissan Chemical Co., Ltd.; Si content: 10%) was used. The balance of each processing solution was water. Moreover, the pH value of each solution was adjusted using NaOH.

#### Examples 6 to 8

[0057] After the trivalent chromate treatment in Example 3, the steel plate was subjected to a topcoating treatment. The conditions for the topcoating treatment used herein are summarized in the following Table 3.

Table 3

| Ex. No.                    | 6  | 7   | 8   |
|----------------------------|--|---|---|
| Kind of Topcoat            | Silicate type inorganic film                     | Polyurethane type organic film                                  | Methacrylic resin type organic film                 |
| Concn. Of Processing Soln. | 200 mL/L   | 100 mL/L  | Stock solution was used as such                     |
| Processing Conditions      | 45°C - 45 sec                                    | 25°C - 60 sec   | 25°C - 60 sec                                       |
| Name and Origin of Reagent | CC-445 available from Dipsol Chemicals Co., Ltd. | SUPERFLEX R3000 available from Dai-ichi Kogyo Seiyaku Co., Ltd. | DIPCOAT W available from Dipsol Chemicals Co., Ltd. |

### Comparative Example 1

[0058] A steel plate, which had been plated with zinc in a thickness of 8  $\mu$ m, was subjected to a hexavalent chromate treatment. The hexavalent chromate bath used herein was Z-493 (10 mL/L) available from Dipsol Chemicals Co., Ltd..

### Comparative Example 2

[0059] A steel plate, which had been plated with zinc in a thickness of 8  $\mu$ m, was subjected to a trivalent chromate treatment using a processing solution having the following composition: 15 g/L (3.3 g/L as expressed in terms of  $\text{Cr}^{3+}$ ) of  $\text{Cr}(\text{NO}_3)_3$ ; 10 g/L of  $\text{NaNO}_3$ ; and 10 g/L of oxalic acid dihydrate (pH: 2.0, adjusted using  $\text{NaOH}$ ). In this respect, the processing was carried out at 30°C for 40 seconds.

### Comparative Example 3

[0060] A steel plate, which had been plated with zinc in a thickness of 8  $\mu$ m, was subjected to a trivalent chromate treatment using a processing solution having the following composition as disclosed in the example of J.P. KOKAI No. 2000-509434: 50 g/L (9.8 g/L as expressed in terms of  $\text{Cr}^{3+}$ ) of  $\text{CrCl}_3 \cdot 6\text{H}_2\text{O}$ ; 3 g/L (1.0 g/L as expressed in terms of Co) of  $\text{Co}(\text{NO}_3)_2$ ; 100 g/L of  $\text{NaNO}_3$ ; and 31.2 g/L of malonic acid (pH: 2.0, adjusted using  $\text{NaOH}$ ). In this respect, the processing was carried out at 30°C for 40 seconds. Processing Steps:

In these Examples and Comparative Examples, the details of the processing steps are as follows:

Plating  $\rightarrow$  Water Rinsing  $\rightarrow$  Activation with Dilute Nitric Acid  $\rightarrow$  Water Rinsing  $\rightarrow$  Trivalent Chromate Treatment  $\rightarrow$  Water Rinsing  $\rightarrow$  (Topcoating Treatment)<sup>1</sup>  $\rightarrow$  Drying<sup>2</sup>  $\rightarrow$  (Heat Treatment)<sup>3</sup>

Note 1: This step was used only when the steel plate was subjected to a topcoating treatment.

Note 2: The drying step was carried out at a temperature ranging from 60 to 80°C for 10 minutes.

Note 3: When carrying out the test for corrosion resistance after heating, each steel plate was treated at 200°C for 2 hours. Salt Spray Test:

[0061] The zinc plated steel plates obtained in Examples 1 to 8 and Comparative Examples 1 to 3 were inspected for the appearance and subjected to the salt spray test (JIS-Z-2371). The results thus obtained are summarized in the following Table 4.

[0062] Moreover, the trivalent chromate films obtained in Examples 1 to 5 and Comparative Examples 1 to 3 were heat-treated at a temperature of 200°C for 2 hours and then examined by the salt spray test (JIS-Z-2371). The results thus obtained are also summarized in the following Table 4.

[0063] As will be clear from the data listed in Table 4, it is found that even the films obtained in Examples 1 to 5 show the corrosion resistance almost identical or superior to that observed for the conventional chromate film (Comparative Example 1). In particular, the corrosion resistance observed for the films of Examples never undergo any change or reduction after the heat treatment. In addition, the films of Examples 6 to 8, which were subjected to a topcoating treatment show corrosion resistance superior to that observed for the conventional chromate film.

[0064] Incidentally, the following Table 5 shows the contents of zinc, chromium, cobalt,  $\text{SiO}_2$  and oxalic acid in the chromate films obtained in Examples 1 to 5 and Comparative Examples 1 and 3 and the thicknesses of these films.

Table 4:

| Results of Salt Spray Test (JIS-Z-2371) |                    |                         |        |                   |
|---|--------------------|-------------------------|--------|-------------------|
| Ex. No.                                 | Appearance of Film | Corrosion Resistance(1) |        | Remarks           |
|   |                    | Not Heated              | Heated |                   |
| 1                                       | Pale Blue          | 300                     | 120    | 30°C - 60 seconds |
| 2                                       | Pale Blue          | 500                     | 240    | 30°C - 40 seconds |
| 3                                       | Pale Blue          | 500                     | 480    | 30°C - 40 seconds |
| 4                                       | Pale Blue          | 500                     | 480    | 30°C - 40 seconds |
| 5                                       | Pale Blue          | 500                     | 480    | 30°C - 40 seconds |

(1) Time (hour) required for the formation of white rust (5%).

Table 4: (continued)

| Results of Salt Spray Test (JIS-Z-2371) |                          |                         |                    |                    |
|---|--------------------------|-------------------------|--------------------|--------------------|
| Ex. No.                                 | Appearance of Film       | Corrosion Resistance(1) |                    | Remarks            |
| 6                                       | Milky White              | Not less than 1000      | Not less than 1000 | Possessing topcoat |
| 7                                       | Milky White              | Not less than 1000      | Not less than 1000 | Possessing topcoat |
| 8                                       | Milky White              | Not less than 1000      | Not less than 1000 | Possessing topcoat |
| 1*                                      | Reddish Green            | 240                     | 24                 | 25°C - 30 seconds  |
| 2*                                      | Pale Blue                | 24                      | 24                 | 30°C - 40 seconds  |
| 3*                                      | Purply and reddish green | 72                      | 48                 | 30°C - 40 seconds  |

(1) Time (hour) required for the formation of white rust (5%).

\*: Comparative Example

Table 5:

| Contents of Zn, Cr, Co, Oxalic Acid and SiO <sub>2</sub> and Thickness of Film |                                  |                         |                         |  |  |                     |
|--|----------------------------------|-------------------------|-------------------------|--|--|---------------------|
| Ex. No.  | Zn Content (mg/dm <sup>2</sup> ) | Cr/(Cr+Zn) (mass ratio) | Co/(Cr+Co) (mass ratio) | C <sub>2</sub> O <sub>4</sub> <sup>2-</sup> / (C <sub>2</sub> O <sub>4</sub> <sup>2-</sup> +Cr) (mass ratio) | SiO <sub>2</sub> Content (mg/dm <sup>2</sup> ) | Film Thickness (μm) |
| 1  | 0.50                             | 33                      | 4                       | 17   | 1.20   | 0.07                |
| 2  | 0.60                             | 33                      | 6                       | 17   | 2.00   | 0.08                |
| 3  | 0.60                             | 33                      | 12                      | 17   | 1.20   | 0.08                |
| 4  | 0.60                             | 34                      | 11                      | 16   | 1.20   | 0.09                |
| 5  | 0.60                             | 34                      | 11                      | 16   | 2.20   | 0.09                |
| 1*   | 1.30                             | 68                      | 0                       | 0  | 0.00   | 0.30                |
| 3*   | 2.20                             | 31.1                    | 3                       | 0  | 0.00   | 0.10                |

\*: Comparative Example

## Claims

1. A processing solution for forming a hexavalent chromium free, corrosion resistant trivalent chromate conversion film on zinc or zinc alloy plating layers, which comprises:

a silicon compound;

trivalent chromium and oxalic acid in a molar ratio ranging from 0.5/1 to 1.5/1, wherein the trivalent chromium is present in the form of a water-soluble complex with oxalic acid; and

cobalt ions, which are stably present in the processing solution without causing any precipitation due to formation of a hardly soluble metal salt with oxalic acid;

wherein the solution reacts with zinc when bringing it into contact with the zinc or zinc alloy plating to form a hexavalent chromium free, corrosion resistant, trivalent chromate conversion film containing zinc, trivalent chromium, cobalt, oxalic acid and SiO<sub>2</sub> on the plating.

2. The processing solution according to claim 1 wherein the silicon compound is acidic colloidal silica.
3. The processing solution according to claim 1 wherein molar ratio of trivalent chromium to oxalic acid ranges from 0.8/1 to 1.3/1.
4. The processing solution according to claim 1 wherein the trivalent chromium concentration ranges from 0.2 to 5 g/L, the oxalic acid concentration ranges from 0.2 to 13 g/L, the cobalt ion concentration ranges from 0.2 to 10 g/L.



L and the silicon concentration ranges from 1 to 20 g/L.

5. The processing solution according to claim 1 wherein the trivalent chromium concentration ranges from 1 to 5 g/L, the oxalic acid concentration ranges from 2 to 13 g/L, the cobalt ion concentration ranges from 0.5 to 8 g/L and the silicon concentration ranges from 2 to 10 g/L.
6. The processing solution according to claim 1 which further comprises 1 to 50 g/L of an inorganic salt selected from the group consisting of inorganic salts of nitric acid, sulfuric acid and hydrochloric acid.
7. The processing solution according to claim 1 wherein pH ranges from 0.5 to 4.
8. The processing solution according to claim 1 wherein the silicon compound is acidic colloidal silica; molar ratio of trivalent chromium to oxalic acid ranges from 0.8/1 to 1.3/1; the trivalent chromium concentration ranges from 1 to 5 g/L, the oxalic acid concentration ranges from 2 to 13 g/L, the cobalt ion concentration ranges from 0.5 to 8 g/L and the silicon concentration ranges from 2 to 10 g/L; it further comprises 1 to 50 g/L of an inorganic salt selected from the group consisting of inorganic salts of nitric acid, sulfuric acid and hydrochloric acid; and pH ranges from 0.5 to 4.
9. A hexavalent chromium free, corrosion resistant, trivalent chromate conversion film containing zinc, trivalent chromium, cobalt, oxalic acid and  $\text{SiO}_2$  and formed on zinc or zinc alloy plating layers, wherein the  $\text{SiO}_2$  content thereof ranges from 1 to 10 mg/dm<sup>2</sup>, the mass ratio of trivalent chromium to (trivalent chromium + zinc)  $[\text{Cr}/(\text{Cr} + \text{Zn})]$  is not less than 15/100, the mass ratio of cobalt to (trivalent chromium + cobalt)  $[\text{Co}/(\text{Cr} + \text{Co})]$  ranges from 1/100 to 40/100 and the mass ratio of the oxalic acid to (trivalent chromium + oxalic acid)  $[\text{oxalic acid}/(\text{Cr} + \text{oxalic acid})]$  ranges from 5/100 to 50/100.
10. A hexavalent chromium free, corrosion resistant, trivalent chromate conversion film containing zinc, trivalent chromium, cobalt, oxalic acid and  $\text{SiO}_2$  and formed on zinc or zinc alloy plating layers, wherein the  $\text{SiO}_2$  content thereof ranges from 1 to 5 mg/dm<sup>2</sup>, the mass ratio of trivalent chromium to (trivalent chromium + zinc)  $[\text{Cr}/(\text{Cr} + \text{Zn})]$  is not less than 20/100 to 60/100, the mass ratio of cobalt to (trivalent chromium + cobalt)  $[\text{Co}/(\text{Cr} + \text{Co})]$  ranges from 4/100 to 40/100 and the mass ratio of the oxalic acid to (trivalent chromium + oxalic acid)  $[\text{oxalic acid}/(\text{Cr} + \text{oxalic acid})]$  ranges from 15/100 to 50/100.
11. The film according to claim 10 wherein the trivalent chromate conversion film comprises two layers.
12. The film according to claim 10 wherein the thickness of the film ranges from 0.05 to 2  $\mu\text{m}$ .
13. A method for forming a hexavalent chromium free, corrosion resistant, trivalent chromate conversion film comprising:
  - the step of bringing zinc or zinc alloy plating layers into contact with a processing solution comprising a silicon compound, trivalent chromium and oxalic acid in a molar ratio ranging from 0.5/1 to 1.5/1, wherein the trivalent chromium is present in the form of a water-soluble complex with oxalic acid, and cobalt ions, which are stably present in the processing solution without causing any precipitation due to formation a hardly soluble metal salt with oxalic acid;
  - wherein the solution reacts with zinc to form a hexavalent chromium free, corrosion resistant, trivalent chromate conversion film containing zinc, trivalent chromium, cobalt, oxalic acid and  $\text{SiO}_2$  on the plating.
14. The method according to claim 13 wherein, in the processing solution, the silicon compound is acidic colloidal silica.
15. The method according to claim 13 wherein, in the processing solution, molar ratio of trivalent chromium to oxalic acid ranges from 0.8/1 to 1.3/1.
16. The method according to claim 13 wherein, in the processing solution, the trivalent chromium concentration ranges from 0.2 to 5 g/L, the oxalic acid concentration ranges from 0.2 to 13 g/L, the cobalt ion concentration ranges from 0.2 to 10 g/L and the silicon concentration ranges from 1 to 20 g/L.
17. The method according to claim 13 wherein the processing solution further comprises 1 to 50 g/L of an inorganic

salt selected from the group consisting of inorganic salts of nitric acid, sulfuric acid and hydrochloric acid.

18. The method according to claim 13 wherein the processing solution has pH of 0.5 to 4.

19. The method according to claim 13 wherein, in the processing solution, the silicon compound is acidic colloidal silica; molar ratio of trivalent chromium to oxalic acid ranges from 0.8/1 to 1.3/1; the trivalent chromium concentration ranges from 0.2 to 5 g/L, the oxalic acid concentration ranges from 0.2 to 13 g/L, the cobalt ion concentration ranges from 0.2 to 10 g/L and the silicon concentration ranges from 1 to 20 g/L; the processing solution further comprises 1 to 50 g/L of an inorganic salt selected from the group consisting of inorganic salts of nitric acid, sulfuric acid and hydrochloric acid; and pH ranges from 0.5 to 4.

20. The method according to claim 13 wherein the step of contacting is conducted at a temperature of the solution of 10 to 40 °C for 5 to 600 seconds.

21. A method for forming a hexavalent chromium free, corrosion resistant, trivalent chromate conversion film comprising the steps of:

immersing zinc or zinc alloy plating layers into a dilute nitric acid solution and then water rinsing; subjecting the zinc or zinc alloy plating layers to immersion in a processing solution and then water rinsing, wherein the processing solution comprises a silicon compound, trivalent chromium and oxalic acid in a molar ratio ranging from 0.5/1 to 1.5/1, wherein the trivalent chromium is present in the form of a water-soluble complex with oxalic acid, and cobalt ions, which are stably present in the processing solution without causing any precipitation due to formation of a hardly soluble metal salt with oxalic acid; and drying the resultant;

wherein the solution reacts with zinc to form a hexavalent chromium free, corrosion resistance, trivalent chromate film containing zinc, trivalent chromium, cobalt, oxalic acid and  $\text{SiO}_2$  on the plating.

22. The method according to claim 21 wherein, in the processing solution, the silicon compound is acidic colloidal silica; molar ratio of trivalent chromium to oxalic acid ranges from 0.8/1 to 1.3/1; the trivalent chromium concentration ranges from 0.2 to 5 g/L, the oxalic acid concentration ranges from 0.2 to 13 g/L, the cobalt ion concentration ranges from 0.2 to 10 g/L and the silicon concentration ranges from 1 to 20 g/L; the processing solution further comprises 1 to 50 g/L of an inorganic salt selected from the group consisting of inorganic salts of nitric acid, sulfuric acid and hydrochloric acid; and pH ranges from 0.5 to 4.

23. The method according to claim 21 wherein the step of immersing is conducted at a temperature of the solution of 10 to 40 °C for 5 to 600 seconds.

24. The method according to claim 21 wherein the step of immersing is conducted at a temperature of the solution of 20 to 30 °C for 20 to 60 seconds.

25. The method according to claim 21 wherein the step of immersing is conducted at a temperature of the solution of 10 to 40 °C for 5 to 600 seconds and the step of drying is conducted at a temperature of 60 to 80 for 10 minutes.

26. The method according to claim 21 wherein, before or after the step of drying, further a topcoat film is applied onto the hexavalent chromium free, corrosion resistant, trivalent chromate conversion film.

27. The method according to claim 21 which, before or after the step of drying, further comprises applying a topcoat film onto the hexavalent chromium free, corrosion resistant, trivalent chromate conversion film by immersing the film in a topcoating solution comprising one member selected from the group consisting of a silicate or a phosphoric acid salt, polyethylene, polyvinyl chloride, polystyrene, polypropylene, methacrylic resin, polycarbonate, polyamide, polyacetal, fluorine plastic, urea resin, phenolic resin, unsaturated polyester resin, polyurethane, alkyd resin, epoxy resin and melamine resin.

28. The method according to claim 27 wherein the topcoating solution comprises one member selected from the group consisting of a silicate acid salt, methacrylic resin and polyurethane.

29. A method for forming a colored hexavalent chromium free, corrosion resistant, trivalent chromate conversion film comprising:

the step of bringing zinc or zinc alloy plating layers into contact with the processing solution of claim 1 further containing a dye, or the steps of bringing zinc or zinc alloy plating layers into contact with the processing solution of claim 1 and then applying to the resultant a solution containing a dye.

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FIG. 1  
pH curves

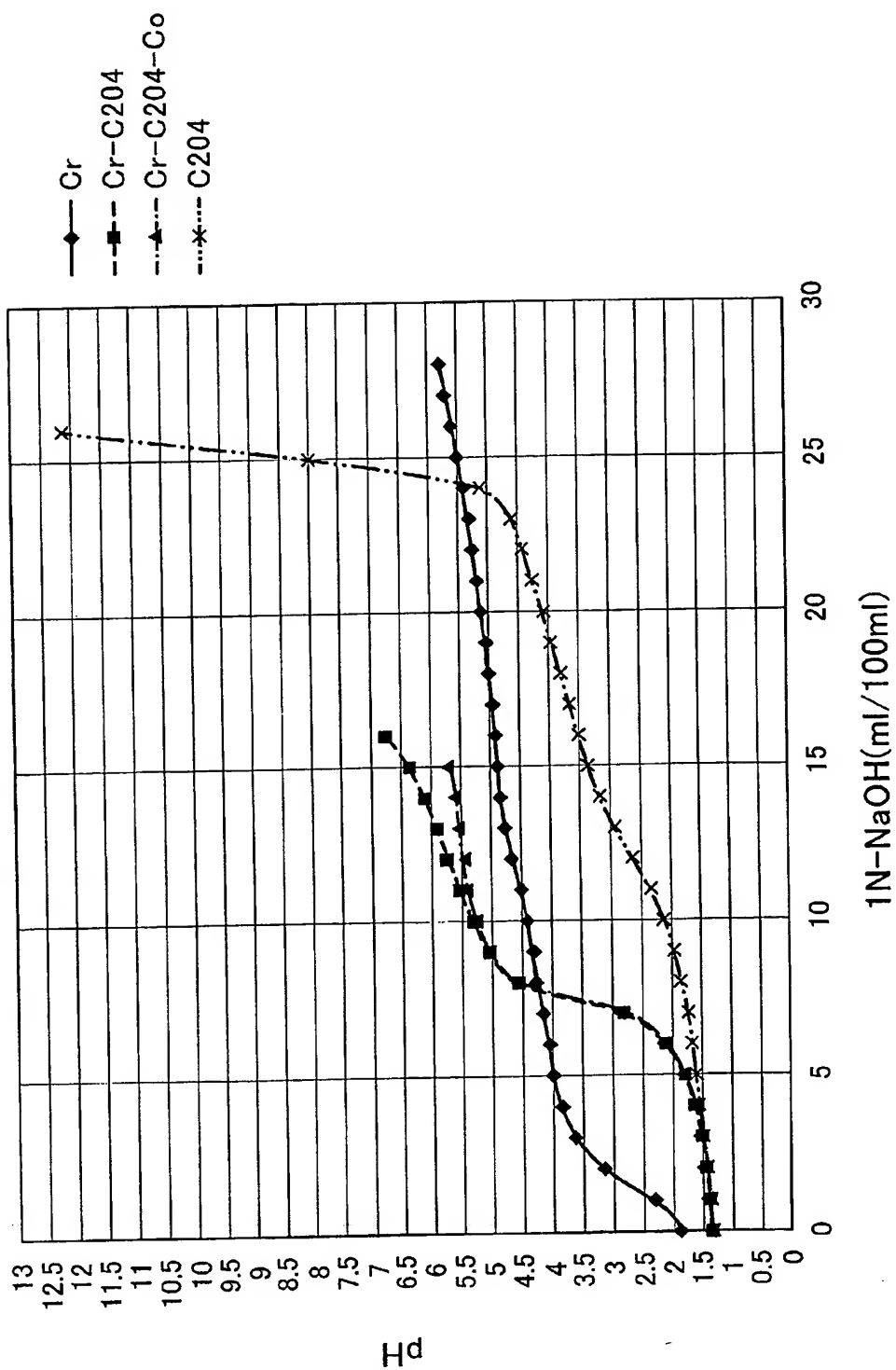


FIG. 2

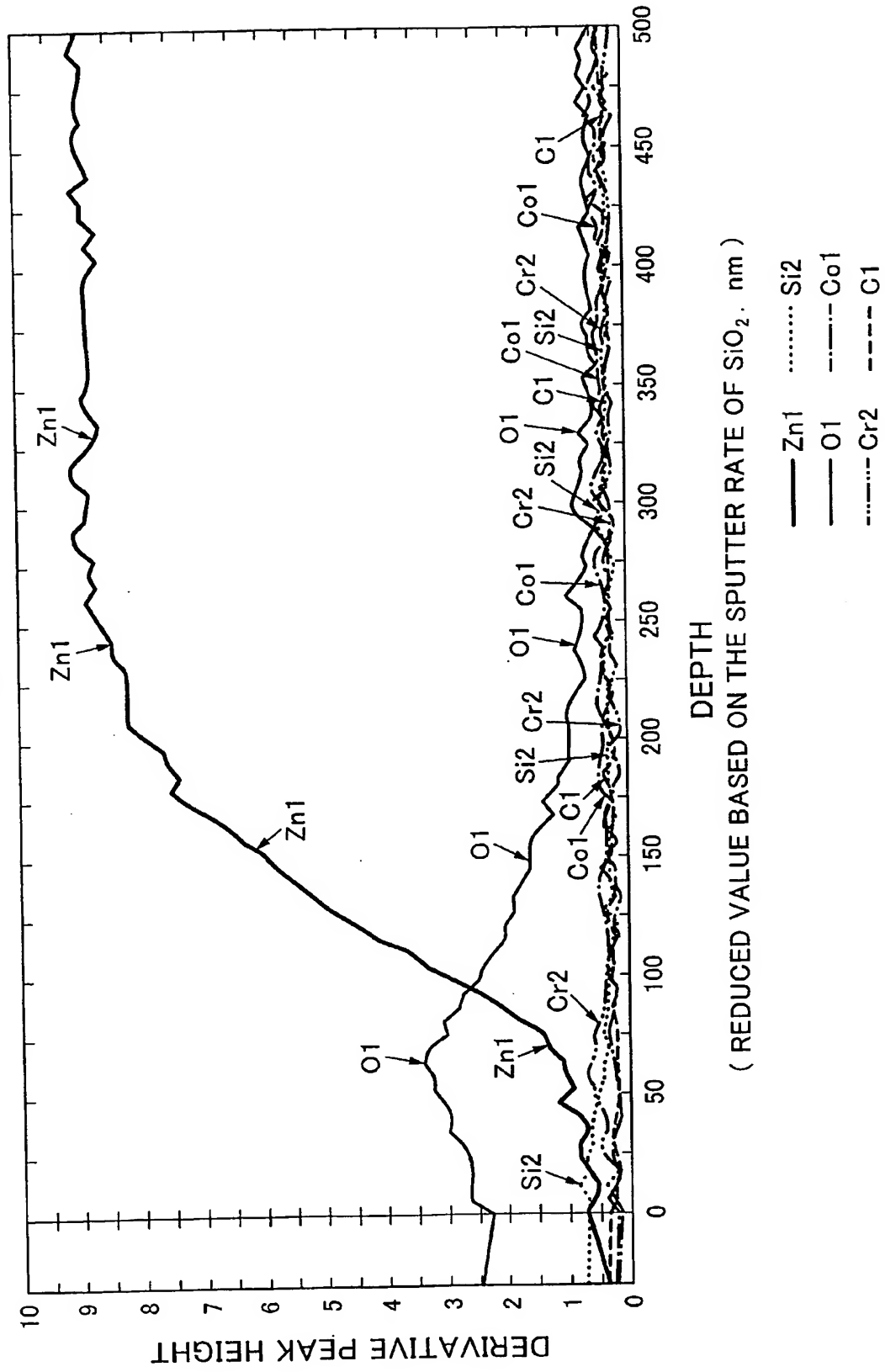


FIG. 3

